Call for Papers

ISPlasma2025/IC-PLANTS2025
17th International Symposium on Advanced Plasma Science and its Applications for Nitrides and Nanomaterials, 18th International Conference on Plasma-Nano Technology & Science

March 3-7, 2025
Chubu University
Aichi, Japan

Plasma Science & Technologies
- Plasma Source
- Modeling & Simulation
- Thin Film Deposition Process
- Flexible Electronics
- Advanced Plasma Diagnostics
- Plasma in Liquid
- Etching Process
- Plasma for Nano&Green Technologies
- Thermal Plasma
- Aerospace/Space Applications

Nitride Semiconductors
- Crystal Growth of GaN & Related Materials
- Characterization
- Optical & Optoelectronic Devices
- MBE Growth & Nitrogen Source
- Device Processing
- Electron & Power Devices

Related Fields

Bio Applications
- Plasma Biology & Medicine
- Plasma Agriculture
- Biomaterials
- Biomarkers
- Bioimaging
- Bio-Devices, µTAS, Lab on a Chip
- Biosensors
- Device Fabrication Technologies

Nanomaterials
- Nanodots & Nanoparticles
- 2D Nanomaterials
- Composite & Functionally Graded Materials
- Applications for Energy
- Nanotubes, Nanowires & Nanorods
- Porous Materials & Membranes
- Surface Modification & Functionalization
- Nanomedicine & Sensing

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http://www.isplasma.jp/

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